To: Commissioner of Patents and Trademarks Washington, D.C. 20231

Fr: George O. Saile

Reg. No. 19,572

28 Davis Avenue

Poughkeepsie, N.Y. 12603

Subject:

Divisional Patent Application of

Serial No.: 10/038,389 1/3/02

YING-LANG WANG, SHI-CHI LIN, YI-LUNG CHENG, CHI-WEN LIU, MING-HUA YOO, WEN-KUNG CHENG,

JIAN-KWANG WANG

IMPROVED CMP PROCESS LEAVING NO RESIDUAL

OXIDE LAYER OR SLURRY PARTICLES

## PRELIMINARY AMENDMENT

Dear Sir:

This is a preliminary amendment for the above referenced Divisional Patent

Application. Please amend the above identified application for patent as follows:

## **CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks, Washington, D.C. 20231, on 1003

(P-3)

Stephen B. Ackerman, Reg. No. 37,761

Signature/Date